Diffusion Analysis across Grain Boundary in Al-3.7 mass%Cu Alloy Using Analytical Electron Microscopy

Fujita Takeshi, Kaneko Kenji, Horita Zenji

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Takeshi Fujita, Kenji Kaneko and Zenji Horita

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An Al–3.7 mass% Cu alloy was subjected to aging treatment at selected temperatures in the range from 453 to 548 K. Diffusion coefficients of Cu in the alloy were then determined from Cu concentration profiles measured across the grain boundary. A high spatial resolution analytical electron microscope (AEM) capable of forming a 1 nm probe was used to measure the concentration profiles. As the aging temperature is lower, the diffusion coefficients tend to deviate from the values extrapolated from the higher annealing temperatures. It is suggested that this deviation is due to the presence of quenched-in excess vacancies. The concentration profiles were also measured for the boundaries having different misorientation angles. It is shown that the concentration profiles are essentially the same regardless of the misorientation angles and of the boundary characters except for the misorientation angles smaller than a few degrees.

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Keywords: Al–3.7 mass% Cu alloy, precipitate free zone, misorientation angle, diffusion coefficient, analytical electron microscopy, X-ray microanalysis

1. Introduction

In many age-hardenable alloys, solute concentration changes near grain boundaries. The formation of precipitate free zones (PFZ) is one of the phenomena arising from the depletion of solute concentration. By making use of the solute depletion around grain boundaries, there are some attempts for the determination of diffusion coefficients.1–5) An advantage of such diffusivity measurements is that neither fabrication of diffusion couples nor deposition of radioactive tracers is required and, more importantly, it is possible to determine diffusion coefficients at lower temperatures than the conventional methods. However, because the diffusion is rather limited in short distances, the measurements of concentration profiles require a high-spatial resolution for quantitative micro-chemical analysis.

Most of the diffusivity measurements from solute profiles across the grain boundaries were performed by analytical electron microscopy (AEM).1–5) Since the AEM was developed by combining transmission electron microscopy (TEM) with micro-chemical analysis, it is capable of reducing the beam spreading in the specimen and thus of increasing the spatial resolution. The first application of AEM was reported by Doig and Edington1) who utilized an electron energy loss spectroscopy (EELS) system in the AEM for the determination of diffusion coefficients of solute atoms in Al–7 mass%Mg and Al–4 mass%Mg alloys. Nicholls and Jones2) employed an energy dispersive X-ray spectrometry (EDS) system in the AEM to determine diffusion coefficients of Zn in an Al–10 mass%Zn alloy. Michael and Williams3) also used an EDS system to examine solute profiles of moving grain boundaries in an Al–4.7 mass%Cu alloy. A comprehensive review concerning the application of AEM to diffusivity measurement was given by Williams and Edington.5)

In this study, Cu solute profiles are measured across grain boundaries in an Al–3.7 mass%Cu alloy using an advanced AEM system capable of forming a 1 nm probe and of operating a scanning mode to achieve elemental mapping. The diffusion coefficients of Cu in the alloy are determined from the Cu profiles obtained after aging treatments at lower temperatures. This study also examines the effect of misorientation angle on the Cu profiles.

2. Experimental

An ingot of an Al–3.7 mass%Cu alloy was prepared by melting with an induction furnace and casting into a steel mold with dimensions of $15 \times 100 \times 150$ mm$^3$. The ingot was homogenized at 833 K for 18 ks (5 h) in air. The impurity level of the alloy is about 0.02% for each of Fe and In and about 0.01% for any of Si, Ti, Pb and Ga. The ingot was swaged into rods with diameters of 10 mm and cut into lengths of 60 mm. The rods were solution-treated at 823 K for 3.6 ks (1 h) and quenched into iced water. At this stage, TEM observation confirmed no precipitation occurred within grains or at grain boundaries. The rods were cut to thicknesses of 20 mm and each piece was subjected to aging at the conditions shown in Table 1. The aging was always terminated by water quenching. The aged samples were sliced and ground mechanically and finally electropolished in a solution of 20% HNO$_3$ and 80% CH$_3$OH to prepare thin specimens for TEM and AEM. All specimens were kept in a refrigerator at 255 K to prevent from nucleation and growth of GP zones before electro-thinning for electron microscopy.

In this study, a JEM-2010FEF analytical electron microscope with a thermal Schottky type of a field emission gun was used at 200 kV. This AEM is capable of forming the

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<tr>
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<tr>
<td>498</td>
<td>3.6 (1)</td>
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3. Results

Figure 1 shows microstructures observed using the conventional TEM from the specimens (a) aged at 523 K for 1.8 ks (0.5 h) and (b) aged at 453 K for 25.2 ks (7 h). For the former specimen, particles of a stable $\theta$ phase ($\text{Al}_2\text{Cu}$) are visible on the grain boundary with dark contrasts but few particles are present within the grains. It should be noted that the striped contrasts visible in the upper grain were formed during the process of electropolishing for TEM. The latter specimen contains many particles which were identified as metastable $\theta'$ ($\text{Al}_3\text{Cu}$) precipitates through an electron diffraction analysis. A PFZ is also clearly visible around the grain boundary. Although the number was very limited, the formation of the stable $\theta$ phase particles was confirmed on some parts of grain boundaries.

X-ray mapping was carried out in the STEM mode for the specimen shown in Fig. 1(a). The results obtained with the Cu K$\alpha$ line and the Al K$\alpha$ line are given in Figs. 2(a) and (b), respectively. Brighter dots represent more inclusions of Cu and Al. With reference to the STEM image observed before the X-ray mapping, Cu-enriched regions and Cu-depleted regions lie along the grain boundary and the former regions correspond to the $\theta$ phase particles. Depletion of Al is visible at the regions where the $\theta$ phase particles are present.

Figure 3 shows (a) an annular dark-field (ADF) image taken in the STEM mode, (b) a Cu K$\alpha$ intensity map and (c) an Al K$\alpha$ intensity map for the specimen shown in Fig. 1(b). In Fig. 3(a), the bright contrasts correspond to Cu-enriched regions and thus, in consistence with the microstructures shown in Fig. 1(b), there are many Cu-enriched $\theta'$ particles with elongated shapes. These particles are not present in the vicinity of the grain boundary, thereby indicating the formation of PFZ. The Cu depletion associated with the PFZ is more clearly demonstrated in Fig. 3(b) by the X-ray mapping using the Cu K$\alpha$ line, which was taken from the same region as Fig. 3(a). It is apparent that the grain boundary and its vicinity contain less numbers of bright dots. From the Al K$\alpha$ intensity map shown in Fig. 3(c), bright dots are distributed homogeneously throughout the scanned area and there is no region devoid of bright dots along the grain boundary. This indicates that neither depletion of Al nor preferential etching of the sample occurred along the grain boundary.

The rectangles are selected as shown in Figs. 2(a) and (b) and the Cu K$\alpha$ and Al K$\alpha$ intensities within the rectangles are integrated in the direction parallel to the grain boundary. These integrated intensities are then plotted in Fig. 4 along the long axes with the position of the grain boundary taken as the origin. Here, the Cu K$\alpha$ intensities are converted to the concentration of Cu by considering the fact that the characteristic X-ray intensity is linearly related to the weight fraction of a constituent element when the X-ray absorption is negligibly small and an analyzed area has an equal thickness. For this study, the absorption of the Cu K$\alpha$ line is less than 1% in the Al–3.7 mass% Cu alloy and the condition of an equal thickness has been fulfilled because the Al K$\alpha$ line has a constant intensity throughout the rectangle. Note that the absorption of the Al K$\alpha$ line is less than 10% in the sample with the thickness up to 600 nm. To determine the proportional constant between the Cu K$\alpha$ intensity and the Cu concentration, the intensities sufficiently apart from the grain boundary was equated to 3.7 mass% from the equilibrium concentration for Cu. The Cu concentration decreases towards the grain boundary and takes a minimum at the

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electron probe size of about 1 nm and of making elemental mapping analysis using a JEM-2200F X-ray spectral-imaging system in the scanning-TEM (STEM) mode. X-rays were measured using a Si(Li) type of a Noran energy dispersive X-ray spectrometer with an ultrathin window. Specimen drift was automatically corrected by an image-tracking system within the EDS system during each elemental mapping analysis. Specimens were tilted so that all analyzed boundaries were aligned parallel to the incident beam. No grains were oriented at Bragg diffraction conditions to avoid any dynamical effect. Thin regions were selected to minimize beam spreading. For the measurement of misorientation angles between neighboring grains, Kikuchi-line patterns were recorded by focusing a beam at the individual grains with the diffraction mode. The diffraction patterns were then analyzed to determine the misorientation angles using a system of the Orientation Determination and Crystallographic Analysis (ORCA). In addition to the analyses using AEM, microstructural observations were carried out at lower magnifications using a Hitachi-8100 transmission electron microscope operating at 200 kV.

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The concentration profile is symmetrical with respect to the grain boundary position. The diffusion coefficients of Cu in the Al–3.7 mass%Cu alloy, $D_{Cu}$, may be determined from the concentration profile measured across the grain boundary through the following Grube equation.\(^7\)

$$C(x) = C_0 + (C_1 - C_0) \text{erf} \left( \frac{x}{2\sqrt{D_{Cu}t}} \right)$$  \hspace{1cm} (1)

Fig. 2  X-ray maps obtained with (a) the Cu Ka line and (b) the Al Ka line for the specimen aged at 523 K for 1.8 ks (0.5 h) shown in Fig. 1(a). The rectangles indicate areas where the X-ray intensities are integrated.

Fig. 3 (a) an annular dark-field (ADF) image, (b) a Cu Ka line map and (c) an Al Ka line map for the specimen aged at 453 K for 25.2 ks (7 h) shown in Fig. 1(b). The rectangles indicate areas where the X-ray intensities are integrated.

Fig. 4  A concentration profile and a variation of the Al Ka line obtained from the integration of the X-ray intensities within the rectangular areas shown in Figs. 2(a) and (b) for the specimen aged at 523 K for 1.8 ks (0.5 h). The solid line represents the best-fit curve for the profile delineated with $D_{Cu} = 2.3 \times 10^{-18} \text{m}^2\text{s}^{-1}$. The two different dotted lines represent the curves delineated with $D_{Cu} = 4.0 \times 10^{-18} \text{m}^2\text{s}^{-1}$ and $1.0 \times 10^{-18} \text{m}^2\text{s}^{-1}$ and they correspond to the upper and lower limits of diffusion coefficient obtained from the best-fit curve.
where \( C(x) \) is the Cu concentration at the position of \( x \) from the grain boundary, \( C_i \) is the equilibrium Cu concentration at the aging temperature, \( C_1 \) is the Cu concentration sufficiently away from the grain boundary, \( r \) is the distance from the grain boundary, \( t \) is the aging time and erf represents the error function. For the determination of \( D_{Cu} \), Doig and Edington \(^{11}\) used the condition of \( \text{erf}(1) \sim 0.84 \) and measured the distance between the grain boundary and the point in the profile corresponding to \( (C(x) - C_0)/(C_1 - C_0) = 0.84 \). In this study, however, the value of \( D_{Cu} \) was determined by fitting eq. (1) to the profile.

For the present alloy, \( C_1 = 3.7 \text{ mass}\% \) and for the concentration profile given in Fig. 4 obtained after aging at 523 K for 0.5 hours, it follows that \( t = 1.8 \text{ ks} \) and it is estimated from the equilibrium phase diagram that \( C_0 = 0.25 \text{ mass}\% \) at 523 K. \(^{31}\) The solid line represents the best-fit curve for the profile with \( D_{Cu} = 2.3 \times 10^{-18} \text{ m}^2\text{s}^{-1} \). Two curves are also delineated in Fig. 4 using two different dotted lines with \( D_{Cu} = 4.0 \times 10^{-18} \text{ m}^2\text{s}^{-1} \) and \( 1.0 \times 10^{-18} \text{ m}^2\text{s}^{-1} \). Although the overall profile involves local zigzag variations of the Cu concentration, such variations fall well within the two dotted curves. Therefore, it is suggested that the corresponding diffusion coefficients may give upper and lower limits of the diffusion coefficient obtained from the best-fit curve.

The same procedure was also taken for the determination of diffusion coefficients from the specimens aged at other temperatures and they are plotted in Fig. 5 against the reciprocal temperature. The published data are included from the results of Doig and Edington \(^{11}\), Peterson and Rothman \(^{8}\) and Fujikawa and Hirano \(^{9}\). However, the reported data are limited in higher temperature regions as drawn with thick dotted line and thick solid line, respectively, and thus, the relations are extrapolated with fine dotted line to a lower temperature region covered in this study. Further included in Fig. 5 are the results of Doig and Edington \(^{11}\) obtained at a low temperature range from the analysis of solute profiles across the grain boundary. It is apparent that the diffusion coefficients obtained at higher temperatures in this study stay close to the extrapolated line and the line of Doig and Edington but the present data points deviate gradually from the published results with decreasing the temperature. This deviation reaches almost one order of magnitude at 453 K. The reason for this deviation will be discussed in the later section.

Figure 6 shows the Cu concentration profile and the variation of the Al K\( \alpha \) intensity obtained after aging at 453 K for 25.2 ks (7 h). They are drawn from the integration of the Cu K\( \alpha \) intensity and the Al K\( \alpha \) intensity in the rectangular areas shown in Figs. 3(b) and (c) in the same way as described above. The solid line represents the best-fit curve for the concentration profile whereas the dotted curve is delineated using the diffusion coefficient extrapolated from the high-temperature region to 453 K. It is apparent that the dotted line is far beyond the fitting even if the local zigzag variations are taken into consideration. The constant variation of the Al K\( \alpha \) intensity indicates that the Cu depletion is not due to the preferential etching at the grain boundary.

The concentration profile obtained after aging at 453 K for 25.2 ks (7 h) is again shown in Fig. 7 but it is now given as a function of Boltzmann parameter, \( \lambda = x t^{-1/2} \), instead of distance, \( x \). This is to plot with the profile obtained after aging at 453 K for 10.8 ks (3 h) and to examine any effect of the aging time on the profiles. Despite the fact that the aging time is different by more than a factor of 2, there is no appreciable difference between the two profiles. This plot indicates that the Cu diffusion to the grain boundary occurs in the manner...
independent of the aging time and the higher diffusion coefficients obtained at lower temperatures are not due to the difference in the aging time.

The concentration profile after aging at 453 K for 25.2 ks (7 h) shown in Fig. 6 is further plotted in Fig. 8 together with another profile obtained from a different grain boundary in the same aged specimen. The misorientation angle for the former grain boundary is 37 degrees and that for the latter is 48 degrees. Although both boundaries are of high-angle grain boundaries, the latter corresponds to a $\Sigma 15$ coincidence site boundary whereas the former is a complete random boundary. There is no difference in the profile between the two boundaries despite the difference in the grain boundary character. This result indicates that the Cu diffusion is not affected by the grain boundary character.

A comparison is also made in Fig. 9 for the concentration profiles measured across three different grain boundaries having misorientation angles of 2, 12 and 56 degrees in a specimen aged at 473 K for 7.2 ks (2 h). According to the conventional grouping for low-angle and high-angle boundaries, the former two boundaries belong to low-angle boundaries and the latter boundary to a high-angle boundary. A detailed analysis showed that the latter boundary is also equivalent to a $\Sigma 3$ coincidence site boundary. The formation of $\theta$ phase particles were confirmed on all boundaries but the formation was more continuous for the 2-degree boundary. The concentration profiles were measured at positions between two neighboring particles on the boundaries. There is no significant difference between the profiles for the 12-degree boundary and the 56-degree boundary, both having appreciable depletions of Cu at and near the boundaries. However, no appreciable Cu depletion was detected for the 2-degree boundary and thus, its concentration profile is significantly different from the others. It is considered that the Cu diffusion across the low angle boundary occurs in essentially the same manner as in the lattice due to no significant change in lattice alignment.

4. Discussions

The measurements of concentration profiles across the grain boundaries after aging of the Al–3.7 mass%Cu alloy at lower temperatures has led to a deviation of the diffusion coefficients above the line extrapolated from a high temperature range reported in the literature. This deviation was
The equilibrium vacancy concentration, equivalent to the ratio of the excess vacancy concentration to one. Doig and Edington determined the diffusion coefficients from the concentration profiles across grain boundaries in an Al–4 mass% Cu alloy after aging at a temperature in the range from 463 to 573 K. The procedure for the diffusivity determination is very similar to the one employed in the present study except that Doig and Edington used the condition of $\text{erf}(1) \approx 0.84$ rather than fitting eq. (1) to the profile. However, the more important difference is that the alloy used in their experiments was subjected to quenching to 573 K for 60 s. after solution treatment at 813 K but before quenching into iced water. This step quenching should have been effective in removing excess vacancies and resulted in good agreement with the extrapolated line.

The present study has clearly demonstrated that there is no difference in the concentration profile if the misorientation angle is larger than a few degrees. It has also been demonstrated that the grain boundary character does not affect the concentration profile. These results are well consistent with the earlier reports of Unwin et al. and Cornish and Day for the measurements of PFZ widths after aging of Al–Zn–Mg alloys. The present experiment concludes that the Cu diffusion towards the grain boundary during the aging process of the Al–3.7 mass% Cu alloy is influenced by the excess vacancy concentration but it is not by the boundary character and misorientation angle unless the angle is less than a few degrees.

5. Summary and Conclusions

(1) The diffusion coefficients of Cu in an Al–3.7 mass% Cu alloy were determined from the concentration profiles measured across grain boundaries after aging at selected temperatures in the range from 453 to 548 K. A high-spatial-resolution analytical electron microscopy was applied for this determination.

(2) The determination of the diffusion coefficients included X-ray mapping, integration of the X-ray intensities, construction of concentration profiles and fitting the Grube equation to the profiles.

(3) The diffusion coefficients tended to deviate to higher values above the line extrapolated from the relationship available in a high temperature range published in the literature. This deviation was more pronounced as the aging temperature is decreased. It was considered that this deviation is attributed to the presence of excess vacancies formed after rapid quenching following solution treatment.

(4) The concentration profiles and thus the resultant diffusion coefficients were affected by neither grain boundary character nor by the grain boundary misorientation angle except for the grain boundary having the angle of less than a few degrees.

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REFERENCES